## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:

Attorney

Kirk D. Prall, et al.

Docket Number: MICR131.02 9-31-02

Serial No: 09/503,638 ) Group Art Unit: 2814

Ormiston & McKinney

Filed: February 14, 2000 ) Examiner: G. Peralta

For: RANDOM ACCESS MEMORY )

September 17, 2002

Assistant Commissioner of Patents Washington, DC 20231

SEP 1 7 2002

**TECHNOLOGY CENTER 2800** 

Sir:

## RESPONSE TO THE OFFICE ACTION MAILED JUNE 19, 2002

Please amend the Application as follows.

## In The Claims

Cancel Claim 29.

Substitute the following amended claims for the original claims having the same number.

26.(amended once)

A semiconductor memory device, comprising:

a silicon structure having a first conductivity type;

pagate electrode over the silicon structure;

If Ma capacitor contact region in the silicon structure adjacent to one side of the gate electrode;

a bit line contact region in the silicon structure adjacent to the other side of the gate electrode;

a first dopant implant in the capacitor and bit line contact regions, the first dopant having a second conductivity type opposite the first conductivity type;

insulating spacers extending along the sidewalls of the gate electrode and over a portion of the first dopant implant in the capacitor and bit line contact regions; and

RESONSE TO OFFICE ACTION -- 1 09/503,638 MICR131.02